## Electronic Supplementary Information for

## Enhanced Normal-Direction Excitation and Emission of Dual-Emitting

## Quantum Dots on a Cascaded Photonic Crystal Surface

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This file includes:

Supplementary Fig.S1 to Fig.S5



Fig.S1 Modified CPC structure with slope profile for holes' sidewalls (CPCS),  $d_2=0.8*d_1$ . (a) conformal TiO<sub>2</sub> film, (b) non-conformal TiO<sub>2</sub> film over SiO<sub>2</sub> sidewall, two white circles in the top layer are voids in TiO<sub>2</sub> film.



Fig.S2 Reflective efficiency of (a) desired CPC structure, (b) CPCS structures,  $d_1$ =180nm,  $d_2$ =0.8\* $d_1$ , (c) CPCS with 5%-smaller holes ( $d_1$ =171nm), (d) CPCS with 5%-larger holes ( $d_1$ =189nm), (e) CPCS with its second layer 5%-shifted (15nm) in x and y directions, (f) CPCS with 5%-thinner TiO<sub>2</sub> layers (t=171nm), (g) CPCS with 5%-thicker TiO<sub>2</sub> layers (t=189nm), (h) CPCS with non-conformal TiO<sub>2</sub> films on the SiO<sub>2</sub> sidewalls and two voids in TiO<sub>2</sub>.



Fig.S3 Near-field electric field (E<sup>2</sup>) distributions (Blue=0, Red=max) at y=0 cross section for an incident plane wave in the 4-layer CPCS structure (d<sub>1</sub>=180nm, d<sub>2</sub>=0.8\*d<sub>1</sub>, h=110nm, t=180nm, L=350nm) at (a)  $\lambda$ =442nm (excitation), (b)  $\lambda$ =515nm (emission), (c)  $\lambda$ =620nm (emission). The regions between black lines denote the top TiO<sub>2</sub> layers in CPCS structures.



Fig.S4 4×4 QD locations to characterize the CPCS-QD system in square unit cell of CPCS, the positions in 1/8 of the unit cell (position '1', '2', '3' in light blue color) are representative positions of QDs on the surface of CPCS structure because the unit of the CPCS structure has plane symmetry along the x and y directions, and has rotational symmetry.



Fig.S5 Spatially averaged (a) excitation ( $E^2$ ) and (b) emission (power flux through the plane  $z=7.9\mu$ m) of QD at the '1', '2', '3' positions on the surface of bare glass, 1-layer PCS and 4-layer CPCS structures ( $d_1$ =180nm,  $d_2$ =0.8\* $d_1$ , h=110nm, t=180nm, L=350nm), respectively.